Electronic structure of InN studied using soft x-ray emission, soft x-ray absorption, and quasiparticle band structure calculations

L. F. J. Piper,* Leyla Colakerol, Timothy Learmonth, Per-Anders Glans, and Kevin E. Smith
Department of Physics, Boston University, 590 Commonwealth Ave., Boston, Massachusetts 02215, USA

F. Fuchs, J. Furthmüller, and F. Bechstedt
Institut für Festkörpertheorie und -optik Friedrich-Schiller-Universität, Jena Max-Wien-Platz. 1, D-07743 Jena, Germany

Tai-Chou Chen and T. D. Moustakas
Electrical and Computer Engineering Department, Boston University, 590 Commonwealth Ave., Boston, Massachusetts 02215, USA

J.-H. Guo
Advanced Light Source, Lawrence Berkeley National Laboratory, Berkeley, California 94720, USA
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The electronic structure of wurtzite InN(000̅1) thin films has been studied using a combination of soft x-ray emission and absorption spectroscopies. We measured the elementally and orbitally resolved InN valence and conduction bands by recording the N K-edge spectra. Theoretical calculations of the N 2p partial density of states were performed within the GW framework of many body perturbation theory. Good agreement between the experimental spectra and the calculations was obtained, most notably with the energetic location of the In 4d−N 2p hybridized state in the emission spectrum and the angular dependence of the absorption spectra.

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I. INTRODUCTION

Interest in the electronic structure of InN has increased dramatically following improvements in its crystal growth and the subsequent revision of the accepted band gap from approximately 1.9 eV to the much lower value of approximately 0.64 eV.1 The band gap of the InₓGa₁₋ₓN alloy system now spans the entire optical window from the near infrared to the UV.2 Most experimental studies have focused on the optical properties of the band gap and there is a general paucity of spectroscopic measurements of the valence and conduction band densities of states in InN. Recently, the first combined x-ray photoemission spectroscopy (XPS) measurements and density functional theory (DFT) calculations of the valence band structure of single crystalline wurtzite InN have been reported.3 Studies of well prepared polar InN samples using both high resolution angle resolved photoemission spectroscopy (ARPES) and high resolution electron energy-loss spectroscopy revealed significant electron accumulation near the film surface, leading to quantum well states in a layer extending from the surface up to 80 Å below it.4,5 Recent calculations have reported that the microscopic origin of the intrinsic electron accumulation at well-prepared polar InN surfaces is due to In-In bonds, within the In bilayer reconstruction, resulting in surface states above the conduction band minimum.6 Surface states have yet to be observed on InN using ARPES, but In-adlayer reconstructions have been experimentally verified.7,8

We report here the results of a combined soft x-ray emission spectroscopy (XES) and soft x-ray absorption spectroscopy (XAS) study of the N 2p partial density of states (PDOS) of the valence and conduction bands. Theoretical calculations for the quasiparticle (QP) band structure were performed in the GW framework to calculate the N 2p PDOS. Good agreement between theory and experiment was obtained. Both XES and XAS involve a transition between electronic states within the solid, one of which is a localized core level (in this case the N 1s). The measured emission or absorption spectrum can then be interpreted in terms of the density of occupied valence band or unoccupied conduction band states, respectively.9,10

II. EXPERIMENT

The 1000 nm thick wurtzite InN(000̅1) thin films were grown on c-plane sapphire substrates by radio frequency plasma-assisted molecular beam epitaxy at 550 °C, at a rate of 0.9 μm/h.15 A low temperature (280 °C) thin InN buffer layer (~30 nm) was grown between the InN film and the sapphire substrate. The samples were autodoped n-type with a measured carrier concentration of n = 1 × 10¹⁰ cm⁻³. The N K-edge XAS and XES were measured at undulator beamline 7.0.1 at the Advanced Light Source (ALS), Lawrence Berke-
ley National Laboratory, which is equipped with a spherical grating monochromator. The absorption spectra were recorded in the total electron yield (TEY) and total fluorescent yield (TFY) modes with an energy resolution of 0.2 eV. For both measurements, the drain current of a mesh grid was used to monitor the incident light. The incident photon energy was calibrated to a hexagonal BN reference sample, measured during the experiments. Since the x-ray fluorescence process is weak compared to the competing nonradiative deexcitation channels, a larger monochromator slit width is required to acquire reasonable counting statistics of 30 s. Emission spectra were recorded using a Nordgren-type grazing-incidence spherical grating spectrometer with the energy resolution set to 0.4 eV at the N K-edge. The energy resolution of the incoming photons was set to 0.4 eV for the emission spectra measurements. The emission energies were calibrated to the elastic features of emission spectra of the N K-edge of the BN reference sample.

III. COMPUTATIONS

Theoretical calculations of the PDOS for wurtzite InN were computed for comparison with the XES and XAS spectra. Since the final state in the x-ray emission process contains a hole in the valence band rather than the core level, the soft x-ray emission spectra reflect the ground state PDOS provided that the final state rule is valid. To first approximation, N K-edge XAS does reflect an image of the N 2p-orbital projected density of states of empty conduction band states. In general, measured XAS and XES spectra should be compared to calculations which take into account core-hole effects, especially the corresponding transition matrix elements and the Coulomb attraction between core hole and the electron in the conduction or valence bands. Each calculation was performed within the framework of hybrid DFT using the recently proposed HSE03 functional for exchange and correlation. Beyond that, quasiparticle effects were taken into account by a subsequent GW correction of the HSE eigenvalues within the framework of many body perturbation theory. In the GW calculations, the Coulomb potential was screened fully dynamical using the RPA dielectric function based on the HSE eigenvalues and functions. This approach to the QP band structure circumvents the problems related to the negative band gap of InN in DFT-LDA and was found to give reliable results for a large variety of semiconductors and insulators, especially those with shallow d-electrons. The present approach goes beyond previously reported calculations since it is independent of the experimental d-band binding energy and provides access to the d-states PDOS. All calculations were performed using the Vienna Ab initio Simulation Package (VASP). The calculated band gap was found to be 0.71 eV.

IV. RESULTS AND DISCUSSION

Figure 1 presents K-edge-XES (2p→1s) and XAS (1s→2p) spectra from InN on a common calibrated photon energy scale. The XES spectrum is recorded at an angle 20° glancing, using an incident excitation energy of 416.2 eV, well above the absorption threshold. The XAS spectra were recorded in both TFY and TEY modes with the photon beam incident at 20° off grazing. The XES spectrum reflecting the N 2p PDOS is similar to that measured earlier from In$_x$Ga$_{1-x}$N. The valence band maximum (VBM) has been extrapolated from the leading edge of the emission peak and was found to be at a photon energy of 394.6 eV. The TEY and TFY XAS spectra are quite similar to each other, with peaks at the same absorption energies. This similarity between the TFY and TEY spectra was also observed for XAS spectra measured at an angle of 70° off grazing (not shown), and our results at 70° agree with TFY XAS of InN reported earlier. As will be discussed, the N K-edge absorption displays a strong dependence on the angle of incidence of the photon beam consistent with earlier TEY XAS measurements of group III nitrides (including InN). Furthermore, we observe a notable difference between the absorption edge onsets between the TFY and TEY modes for both angles of incidence. This is highlighted in the inset of Fig. 1, which displays an enlarged region close to the VBM. The TFY and TEY absorption onsets (determined from a straight line extrapolation of the leading edge of the absorption) are found to occur approximately 0.8 eV and 1.4 eV above the VBM, respectively. No angular difference in the respective absorp-
tion onsets was observed, which will be discussed later. TFY and TEY modes differ in being more bulk and surface sensitive, respectively. The corresponding bulk Fermi ($E_F$) level for a carrier concentration of $n = 1 \times 10^{19}$ cm$^{-3}$ is 0.86 eV above the VBM (for $E_g = 0.64$ eV, $m^*_n = 0.042m_0$ with a nonparabolic conduction band, and band gap shrinkage effects included). We note agreement between the separation of the extrapolated VBM and the onset of the absorption edge of the TFY XAS and the calculated bulk $E_F$ to VBM separation. A larger separation is expected for the TEY XAS due to the Fermi level being pinned high above the CBM at the surface, due to the intrinsic electron accumulation. A value of 1.4 eV is in agreement with the $E_F$ to VBM separation of InN from surface-sensitive XPS measurements.

To compare the XES and XAS spectra with theoretical calculations, the spectra must be plotted on a common binding energy scale. This was achieved by rigidly shifting the emission and absorption spectra until the extrapolated experimental and calculated valence band maxima were in agreement. The XES spectra were also divided by $E^3$ (where $E$ is the photon energy) to correct for the photon density of states’ contribution to the transition rate. Figure 2(a) presents the normalized XES/$E^3$ spectra for two incident photon energies: $h\nu = 396.7$ eV and 416.2 eV, corresponding to energies close to the absorption threshold and well above the threshold, respectively (see Fig. 1). The above-threshold XES spectral shape represents the local partial density of states (LPDOS), and has been plotted alongside the calculated N 2p PDOS. For comparison, the theoretical N 2p PDOS have been convoluted first using a Lorentzian with a half width at half maximum (HWHM) of 0.3 eV to account for lifetime broadening, and were then further convoluted with a Gaussian of full width at half maximum (FWHM) =0.4 eV for account for experimental resolution. As is evident in Fig. 2, the spectral shape of the above-threshold XES and the calculated PDOS are in good agreement; in both cases a sharp low binding energy peak with a high binding energy shoulder is observed followed by a small well defined peak at $\sim -5.5$ eV below the VBM. We also note a weak peak at $\sim -16$ eV below the VBM in the N K-edge XES. This peak is due to transitions into the N 1s core-hole from electrons in N 2p states hybridized with shallow core level In 4d electrons, and is shown magnified for the above-threshold XES spectrum Fig. 2(a); the calculated position of the In 4d$-N$ 2p hybridized state corresponds well with the energy of this peak. The small shift of the hybridization peak in the theoretical spectrum towards lower binding energies is a consequence of the slight underestimate of the In 4d electron binding in the calculations. A clear shift in the peak closest the VBM towards higher photon energies (lower binding energies) is noted by changing the incident photon energy to 396.7 eV. The XES ($h\nu = 396.7$ eV) spectral shape consists of an incoherent LPDOS contribution and a k-selective coherent contribution. In order to distinguish between these contributions, the largest LPDOS fraction (i.e., the above-threshold XES spectrum) possible has been subtracted from the raw XES ($h\nu = 396.7$ eV) spectrum whilst ensuring a non-negative difference (corresponding to the coherent contribution)—as described elsewhere—and is displayed in FIG. 2. (Color online) (a) Normalized N K-edge XES spectra for two incident photon energies: $h\nu = 396.7$ eV (color online: red circles) and 416.2 eV (black circles) are displayed on a common binding energy axis referenced to the extrapolated VBM ($=0$ eV). Also shown is the broadened theoretical QP-PDOS of the occupied N 2p orbitals, see main text for details. Agreement is observed between the energetic peaks of the calculated PDOS and above-threshold incoherent XES/$E^3$ ($h\nu = 416.2$ eV) spectrum. A In 4d$-N$ 2p hybridized peak is noted in the magnified above-threshold XES/$E^3$ spectrum in agreement with the calculated PDOS. Spectral shape differences are noted between the two emission spectra due to the lower incident energy emission having an additional k-selective coherent component. (b) The raw above-onset XES/$E^3$ ($h\nu = 396.7$ eV) spectrum (color online: red) is plotted along with the incoherent local PDOS contribution (black line) and k-selective coherent contribution (gray filled area). See text for details.

Fig. 2(b). It was found that the highest emission energy peak corresponded to incident photon energy closest to the absorption onset, consistent with the VBM of wurtzite InN lying at the zone center within the bulk. Further work is required in order to determine k-resolved band structure of bulk InN with resonant XES, as recently attempted for GaN.

Due to its wurtzite structure, InN displays a strong angular dependence in N K-edge XAS spectra, as has been observed in all wurtzite group III nitrides. The physical origin of this is due to the scalar multiplication in the matrix element of the absorption cross section: For wurtzite crystals, if the polarization vector of the photon $E$ is perpendicular to the $c$ axis of the crystal ($E \perp c$) then transitions from the
peak is reduced. Figure 3 also presents the calculated contributions to the unoccupied PDOS, such that 20° corresponds to \((\pi/2) N 2p_{\text{xy}} + \pi/4 N 2p_z\) [Fig. 3(a)] and 70° corresponds to \((\pi/2) N 2p_{\text{xy}} + \pi/4 N 2p_z\) [Fig. 3(b)]. The theoretical spectra have been broadened for comparison with the measurements by a convolution with a Lorentzian (FWHM=0.3 eV) followed by a Gaussian (FWHM=0.2 eV) in order to account for lifetime broadening and the instrumental resolution, respectively. For both incident angles, we find good agreement between the XAS spectra and the corresponding PDOS.

We do note a fixed 1.3 eV shift between the experimental and theoretical features. Similarly small energetic shifts between the experimental XAS and theory PDOS of GaN N K-edge, which were attributed to excited-state self-energy corrections. We note that our QP band structure calculations do include excited-state self-energy corrections, therefore we consider this shift here to be due exciting effects. In XAS one may measure the final state of the electron in a bound state such as an exciton, consequently the shift of ~1.3 eV between measured and computed peaks may provide an estimate of the binding energy of the p-like conduction band-N 1s core hole exciton. In agreement with previous TEY XAS experiments, and our QP-corrected DFT calculated PDOS, the measured signal intensity was greater for the 70° spectra, corresponding to the dominant 2p_{xy} states for that geometry. However, once both spectra are scaled to the maximum peak intensity (as shown in Fig. 3), the extrapolated absorption edges are the same within error limits. This result is in contrast with earlier XAS results of InN that reported a 0.8 eV difference between the onsets for the two polarization directions.

Our results are in agreement with the calculated PDOS scaled in the same fashion.

V. CONCLUSION

We have presented an experimental and theoretical study of the valence and conduction band N 2p density of states of wurtzite InN, using soft x-ray emission and absorption spectroscopies and \textit{ab initio} QP band structure calculations. We find excellent agreement between the spectra and the calculations, both in terms of the spectral shape and energetic location of peaks in the emission and absorption spectra, and the angular dependence of the absorption spectra.

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#lfjpiper@physics.org